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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/900,160	07/09/2001	Kia Silverbrook	YU128US	6620	
	7590 04/06/200 NK DESEARCH PTV I		EXAMINER		
SILVERBROOK RESEARCH PTY LTD 393 DARLING STREET			ALANKO, ANITA KAREN		
BALMAIN, 2041 AUSTRALIA			ART UNIT	PAPER NUMBER	
AOSTIGLEM		-	1765		
SHORTENED STATUTOR	Y PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE		
3 MO	NTHS	04/06/2007	PAPER		

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

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		Applicant(s)	
Office Action Summary	09/900,160	SILVERBROOK	
omec Action Summary	Examiner	Art Unit	
The MAII INC DATE of this communication	Anita K. Alanko	1765	
The MAILING DATE of this communication app Period for Reply	pears on the cover sneet with t	ne correspondence address	
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DATE of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICAT 36(a). In no event, however, may a reply will apply and will expire SIX (6) MONTHS . cause the application to become ABAND	TION. be timely filed from the mailing date of this communicatio ONED (35 U.S.C. & 133)	
Status	,		
1) Responsive to communication(s) filed on <u>03 Ja</u> 2a) This action is FINAL . 2b) This 3) Since this application is in condition for alloware closed in accordance with the practice under E	action is non-final.		s
Disposition of Claims			-
4) Claim(s) 1-9 is/are pending in the application. 4a) Of the above claim(s) 4-9 is/are withdrawn 5) Claim(s) is/are allowed. 6) Claim(s) 1-3 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/o Application Papers 9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) accomplicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Examine 11.	r election requirement. er. epted or b) objected to by the drawing(s) be held in abeyance. tion is required if the drawing(s) is	See 37 CFR 1.85(a). s objected to. See 37 CFR 1.121(d).
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document: 2. Certified copies of the priority document: 3. Copies of the certified copies of the priority application from the International Bureau * See the attached detailed Office action for a list	s have been received. s have been received in Appli rity documents have been rec u (PCT Rule 17.2(a)).	cation No. <u>09/112,778</u> . eived in this National Stage	
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 1/3/07.	4) Interview Sumr Paper No(s)/Ma 5) Notice of Inform 6) Other:	ail Date	

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Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claims 1-3 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

The newly added claim limitation of claim 1 of "depositing and etching a layer of actuator material..." is unclear because it is unclear where the layer is deposited. Is it deposited on the wafer substrate or on a separate substrate? It is also unclear as to whether there are two different actuators, or whether one actuator serve as both an ejection and a refill actuator.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-3 are rejected under 35 U.S.C. 103(a) as being unpatentable over Albarda et al (US 5,029,805) in view of Waggener et al (US 4,733,823).

Albarda discloses a method comprising:

providing a wafer substrate 1 with nozzle chambers 7;

depositing and etching a layer of actuator material to define an ejection actuator and a refill actuator for each nozzle chamber (Fig.1-5 all show different actuating methods, and each

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have an actuator that serves to both eject and refill the nozzle chamber, inherently since no separate refill mechanism is disclosed).

Albarta fails to disclose how the nozzle chambers in silicon (col.2, lines 29-34) are formed.

Waggener discloses a method for forming nozzle chambers comprising:

depositing a layer of etch stop material 17 on a front side of a wafer substrate 10 (Fig.4, vol.3, lines 58-61);

etching the substrate up to the etch stop material to define a plurality of nozzle chambers 11 (Fig.1) and so that portions of the etch stop layer define roof walls for respective nozzle chambers (Fig.6); and

etching each said portion of the etch stop layer (the doped layer 17) to form at least one ink ejection port 13 in each said portion (Fig.8).

The advantage of using the method of Waggener is that it uses standard semiconductor wafers without the need for mechanical or chemical polishing of the two major surfaces of the wafer. It would have been obvious to one with ordinary skill in the art to form the nozzle chambers in the method of Albarta by using the method of Waggener because Waggener teaches that it is a useful method for forming nozzle chambers and nozzle openings without the need for mechanical or chemical polishing of the two major surfaces of the wafer, and because it uses known semiconductor techniques that are well known to those skilled in the art, and therefore able to be integrated into silicon processing methods such as that of Albarta.

As to claim 2, Albarta discloses to include drive circuitry on a back side of the wafer substrate (col.5, lines 23-27).

As to claim 3, the method of Albarta includes each actuator connected to drive circuitry (since there is only one actuator that performs both ejection and refill).

Response to Amendment

The 35 USC 102 and 103 rejections over Waggener and Waggener et al (US 4,733,823) in view of Shimada et al (US 5,802,686) are withdrawn in view of the claim amendments adding that the actuator material is deposited and etched.

Claims 1-3 are rejected under 35 U.S.C. 103(a) as being unpatentable over newly cited Albarda et al (US 5,029,805) in view of Waggener et al (US 4,733,823). Albarda discloses depositing and etching actuator material.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. The cited art shows methods of forming actuators for inkjet printheads.

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period

will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Anita K. Alanko whose telephone number is 571-272-1458. The examiner can normally be reached on Mon-Fri until 2:30 pm (Wed until 11:30).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on 571-272-1465. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Anita K Alanko
Primary Examiner
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